

perforated MEA (Microelectrode Array) for MEA2100-32- and USB-MEA32-STIM4-System

pMEA for use with MEA2100-32- and USB-MEA32-STIM4- System

pMEA-32S12 Layout 1



10 °C – 50 °C

49 x 25 mm x 180 µm
Polyimide foil on ceramic
carrier with perforation

pMEA-32S12 Layout 2



10 °C – 50 °C

49 x 25 mm x 180 µm
Polyimide foil on ceramic
carrier with perforation

pMEA-32S12 Layout 3



10 °C – 50 °C

49 x 25 mm x 180 µm
Polyimide foil on ceramic
carrier with perforation

pMEA-32S12 Layout 4



10 °C – 50 °C

49 x 25 mm x 180 µm
Polyimide foil on ceramic
carrier with perforation

Temperature compatibility
Dimension (W x D x H)
Base material

Perforation:
Total area of perforation
Diameter of the holes

Contact pad
Track material

Electrode diameter

Interelectrode distance

Electrode height
Electrode type

Isolation type
Electrode impedance

Electrode layout grid

Number of electrodes

Ring

0.8 mm²
20, 30, 50, 75 and 90 µm

Titanium nitride (TiN)
Titanium (Ti)

30 µm (recording electrode)
50 µm (stimulation electrode)

90 and 150 µm (record. electrode)
100 and 125 µm (stim. electrode)

Planar
Titanium nitride (TiN)

Polyimide foil
30 – 50 kΩ

1x10+1x12+1x10 (record. electr.)
2x6 (stimulation electrodes)

32 recording electrodes
12 stimulation electrodes
1 internal reference electrode

Without ring
Glass ring

0.8 mm²
20, 30, 50, 75 and 90 µm

Titanium nitride (TiN)
Titanium (Ti)

30 µm (recording electrode)
50 µm (stimulation electrode)

90 and 150 µm (record. electrode)
90 and 150 µm (stim. electrode)

Planar
Titanium nitride (TiN)

Polyimide foil
30 – 50 kΩ

1x10+1x12+1x10 (record. electr.)
2x6 (stimulation electrodes)

32 recording electrodes
12 stimulation electrodes
1 internal reference electrode

Without ring
Glass ring

0.8 mm²
20, 30, 50, 75 and 90 µm

Titanium nitride (TiN)
Titanium (Ti)

30 µm (recording electrode)
50 µm (stimulation electrode)

90 and 150 µm (record. electrode)
90 and 100 µm (stim. electrode)

Planar
Titanium nitride (TiN)

Polyimide foil
30 – 50 kΩ

1x10+1x12+1x10 (record. electr.)
3x4 (stimulation electrodes)

32 recording electrodes
12 stimulation electrodes
1 with internal reference electrode

Without ring
Glass ring

0.8 mm²
20, 30, 50, 75 and 90 µm

Titanium nitride (TiN)
Titanium (Ti)

30 µm (recording electrode)
50 µm (stimulation electrode)

100 and 100 µm (record. electrode)
100 and 100 µm (stim. electrode)

Planar
Titanium nitride (TiN)

Polyimide foil
30 – 50 kΩ

4x8 (recording electrode)
2x6 (stimulation electrodes)

32 recording electrodes
12 stimulation electrodes
1 internal reference electrode

Without ring
Glass ring